



## **CLEAN COPY OF THE CURRENT CLAIMS**

- 1. A layered low dielectric constant nanoporous material comprising:
  - a first layer juxtaposing a substrate;
  - a second layer that is nanoporous and juxtaposing the first layer; and
  - an additional layer partially juxtaposing the second layer.
- 2. The material of claim 1, wherein the low dielectric constant material has a dielectric constant no more than 2.5.
  - The material of claim 1, wherein the first layer substantially comprises a nanoporous material.
  - The material of claim 8, wherein the polymer is organic.
- 5. The material of claim 4, wherein the polymer comprises polyarylene ether.
- 8. The material of claim 3, wherein the nanoporous material comprises a polymer.
- 10. The material of claim 1 wherein the second layer substantially comprises a nanoporous polymer.
- 11. The material of claim 10, wherein the polymer comprises at least one of a polyarylene ether or an adamantane-based compound.
- 12. The material of/claim 1, wherein the additional layer comprises an organic compound.
- The material of claim 12, wherein the organic compound substantially comprises at least one of a polyarylene ether or an adamantane-based compound.
- 14. The material of claim 1, wherein the nanoporous material comprises voids having a mean diameter of less than 100 nanometers.
- 15. The material of claim 1, further comprising a layer of metal wire between the substrate and the first layer.

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**PATENT** 

17. The material of claim 15, wherein the metal wire is aluminum or copper.

34. The material of claim 3, wherein the nanoporous material comprises an adamantane-

based compound.